

## EAST Search History

## EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S62	5394	(438/7,10,17).CCLS.	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/09/12 19:16
S63	1521	(700/37,45,172,205,225,299).CCLS.	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/09/12 19:16
S64	6914	S63 or S62	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:16
S65	451	S64 and @pds>"20080405"	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:16
S66	3889	(716/4).CCLS.	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/09/12 19:16
S67	19	S66 and (critical adj3 dimension) and (feedback or feed adj back) same (feedforward or feed adj forward)	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:16
S68	1062	(716/17).CCLS.	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2009/09/12 19:16
S69	1	S68 and (critical adj3 dimension) and (feedback or feed adj back) same (feedforward or feed adj forward)	US-PGRUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:16

S70	4	(S67 or S69) and @pd> "20080405"	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:16
S71	118	(S70 or S65) and @pd> "20090427"	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:16
S72	6979	(non adj photoresist or nitride) with (cd or critical dimension)	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:22
S73	139	(non adj photoresist or nitride) with measur \$6 with (cd or critical dimension)	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:22
S75	7	nitride with non adj photoresist	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 19:23
S90	1	non adj photoresist with top near2 layer	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:00
S91	6279	non adj photo adj resist with top near2 layer	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:03
S92	0	non adj photo adj resist with top near2 layer	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:03
S93	0	non near2 photo adj resist with top near2 layer	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:03
S94	4653	nitride near2 top near2 layer	US-PGRUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:03

S95	384	nitride near2 top near2 layer and semiconductor adj processing	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:03
S96	164	nitride near2 top near2 layer and semiconductor adj processing and exposure	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:04
S97	4	nitride near2 top near2 layer and semiconductor adj processing and exposure near2 energy	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:04
S98	1	top near2 top with poly near2 nitride	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:18
S100	9	(poly adj gate or ploygate) with top adj layer	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:21
S101	773	(poly adj gate or ploygate) with layer and semiconductor with process\$6	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:33
S102	21	(poly adj gate or ploygate) with layer and semiconductor with process\$6 and \$5exposure\$5 with energy	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:33
S103	44725	(poly adj gate or ploygate) with layersame \$5exposure\$5 with energy	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:36
S104	4	(poly adj gate or ploygate) with layer same \$5exposure\$5 with energy	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:36
S105	22	(poly adj gate or ploygate) with \$5exposure\$5	US-PGFUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:37

S106	334	(poly adj gate or ploygate) with top	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:42
S107	3	(poly adj gate or ploygate) with top same exposure	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:42
S108	100	(poly adj gate or ploygate) with (cd or critical with dimension)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:44
S109	4	(poly adj gate or ploygate) with (cd or critical with dimension) same \$5exposur\$5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/12 21:44

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